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(71) Applicant *(for all designated States except US)*: **CIBA HOLDING INC.** [CH/CH]; Klybeckstrasse 141, CH-4057 Basel (CH).

(72) Inventors; and

(75) Inventors/Applicants *(for US only)*: **HAO, Zhimin** [CH/CH]; Brennerstrasse 60, CH-4123 Allschwil (CH). **SCHMIDHALTER, Beat** [CH/CH]; Dahlienstrasse 25, CH-4416 Bubendorf (CH). **BUDRY, Jean-Luc** [CH/CH]; Rue du Raimeux 26, CH-2822 Courroux (CH). **FONTANA, Margherita** [IT/CH]; Falkensteinerstrasse 5, CH-4053 Basel (CH). **TURBIEZ, Mathieu G. R.** [FR/FR]; 15 rue du petit Landeau, F-68170 Rixheim (FR). **BIENEWALD, Frank** [DE/FR]; 63, rue de Hagenthal, F-68220 Hegenheim (FR). **DÜGGELI, Mathias** [CH/CH]; Falkensteinerstrasse 5, CH-4053 Basel (CH). **AEBISCHER, Olivier Frédéric** [CH/CH]; Hasliweg 21, CH-3186 Düdingen (CH). **HAYOZ, Pascal** [CH/CH]; Ettingerstrasse 55, CH-4114 Hofstetten (CH). **FONRODONA TURON, Marta** [ES/CH]; J.J. Balmer-Strasse 5, CH-4053 Basel (CH).

(74) Common Representative: **CIBA HOLDING INC.**; Patent Department, Klybeckstrasse 141, CH-4057 Basel (CH).

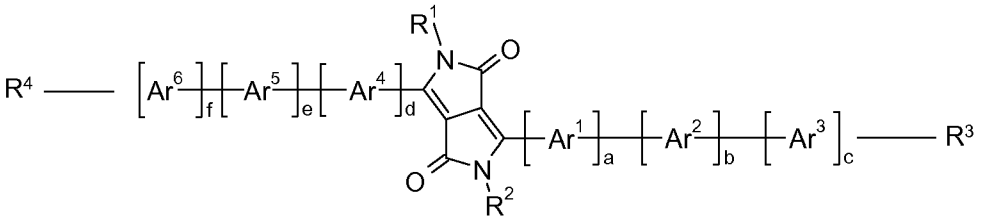
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(I)

(57) Abstract: The present invention relates to compounds of the formula (I) wherein the substituents are as defined in claim 1, and their use as organic semiconductor in organic devices, like diodes, organic field effect transistors and/or a solar cells. The compounds of the formula I have excellent solubility in organic solvents. High efficiency of energy conversion, excellent field-effect mobility, good on/off current ratios and/or excellent stability can be observed, when said compounds are used in semiconductor devices or organic photovoltaic (PV) devices (solar cells).

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